Impedance Matching of 640 GHz SIS Mixer in a High IF Band of 11-13 GHz

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http://smiles.tksc.jaxa.jp http://smiles.tksc.jaxa.jp/~sis



Abstract

Two 640 GHz SIS mixers are used for SMILES, an atmospheric research mission to be aboard the International Space Station. Those SIS mixers, are operated at a relatively high IF band of 11-13 GHz, which is selected from the scientific reason of the mission. That high IF frequency, however, makes it more difficult to match the SIS device to the subsequent 50 Ω IF line. In addition to an impedance difference in real part, parasitic effects due to bonding wires, RF choke circuit as well as the capacitance of the SIS junctions will play an important role. When the IF matching is poor, the SIS mixer under test often exhibits significant gain ripples in its IF characteristics.

A solution for that is to insert a proper impedance transformer between the SIS mixer device and the IF output port and compensate the undesirable parasitic effects. To experimentally derive the output impedance of the SIS device, we have repeated measurements of the receiver gain with respect to an SIS device combined with several different types of matching transformers. We utilized the set of data with different IF characteristics to determine the SIS mixer parameters by means of a fitting technique. This has worked well and allowed us to establish the SIS mixer model to reproduce the measured data.

With a proper impedance transformer designed based on the above fitting results, we successfully realized a small ripple and better flatness in the gain profiles of the mixer.

640 GHz SIS Mixer for SMILES



LO: 637.32 GHz IF: 11-13 GHz

SIS Junction: Nb/AlOx/Nb Junction Size: ~1 x 1 μm² Current Density: 6-7 kA/cm² RF Matching: PCTJ

Sideband Separation: Quasioptical separation with FSP

In some cases of high IF system, the frequency separation between upper and lower sideband is not negligible as compared with the RF bandwidth of an SIS mixer. For SMILES, each mixer is selected to have good performance at each band.



Characteristics of EM Mixer Receiver











Receiver gains and I-V characteristics, measured with different types of transformers and different LO frequencies, were simultaneously fitted to determine SIS device parameters.

> SIS **Mixer** R



Example of Fitting Result :

I-V Characteristic Data 0.25 Model 0.2 (20.18 0.1 0.05 **Receiver Gain** V (mV) 50 Ω Thru Line Gain (dB) -12 <u>-</u> 10 10.5 11 11.5 12 12.5 13 13.5 Frequency (GHz) Transformer No. 1-1 Gain (dB) 11.5 12 12.5 10.5 11 13 13.5 Frequency (GHz) Transformer No. 1-2 -2 Gain (dB) -12 10 10.5 11.5 12 12.5 13.5 11 13

Frequency (GHz)

SIS Device A with $F_{LO} = 654$ GHz

- $J_c = 6813 \text{ A/cm}^2$, $R_n = 15.9 \Omega$
- Relatively high dynamic resistance of 550 Ω at bias point



Example of Fitting Result :

I-V Characteristic Data 0.25 -- Model 0.2 (20.18 0.1 0.05 **Receiver Gain** V (mV) 50 Ω Thru Line Gain (dB) 51-10 -18 <u>–</u> 10 10.5 11 11.5 12 12.5 13 13.5 Frequency (GHz) Transformer No. 1-2 MAN MAN (gp)-10 Gain Gain 10.5 11 11.5 12 12.5 13 13.5 Frequency (GHz) Transformer No. 2-2 (Bp)-10 Gain (10.5 11.5 12 12.5 13.5 11 13

Frequency (GHz)

SIS Device B with $F_{LO} = 618$ GHz

- $J_c = 5962 \text{ A/cm}^2$, $R_n = 13.7 \Omega$
- · Relatively low dynamic resistance of 150 Ω at bias point.

